

Abstract

An object of the present invention is to provide a base for an optical disk which is excellent in mass productivity for substrate formation by a 2P method, exhibits a particularly good releasability from a stamper, and has a strong close adhesive force to a reflective film layer or a dielectric layer even under high temperature and high humidity. The invention relates to an ultraviolet-curable resin composition for a multilayer optical disk, which enables formation of such a base for an optical disk. The ultraviolet-curable resin composition for a multilayer optical disk according to the invention contains (A) a hexa- or higher-functional urethane (meth)acrylate obtained by reacting an organic isocyanate having two or more isocyanate groups in one molecule thereof with a tri- or higher-functional (meth)acrylate having a hydroxyl group, (B) a tri- or lower-functional (meth)acrylate monomer, and (C) a photopolymerization initiator.